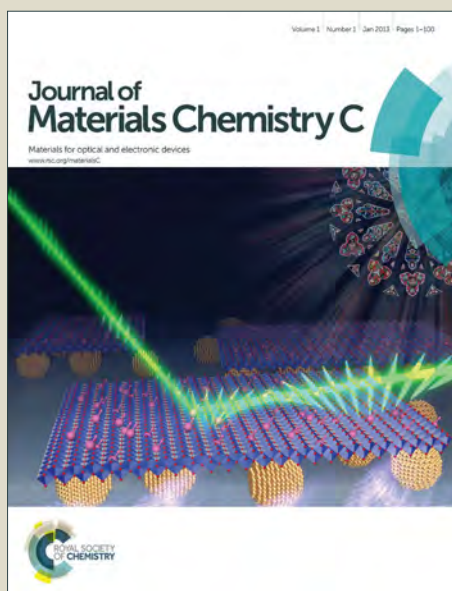


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# Novel temperature stable high- $\epsilon_r$ microwave dielectrics in the $\text{Bi}_2\text{O}_3$ - $\text{TiO}_2$ - $\text{V}_2\text{O}_5$ system

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## Abstract

In the present work, a series of low temperature firing  $(1-x)\text{BiVO}_4\text{-}x\text{TiO}_2$  ( $x=0.4, 0.50, 0.55$  and  $0.60$ ) microwave dielectric ceramics was prepared using traditional solid state reaction method. From back-scattered electron images (BEI), X-ray diffraction (XRD) and energy dispersive analysis (EDS), there was negligible reaction between  $\text{BiVO}_4$  and  $\text{TiO}_2$  at the optimal sintering temperature  $\sim 900^\circ\text{C}$ . As  $x$  increased from  $0.4$  to  $0.60$ , permittivity ( $\epsilon_r$ ) increased from  $81.8$  to  $87.7$ , quality factor value ( $Qf$ ) decreased from  $12,290$  to  $8,240$  GHz and temperature coefficient (TCF) shifted from  $-121$  to  $+46$  ppm/ $^\circ\text{C}$ . Temperature stable microwave dielectric ceramic was obtained in  $0.45\text{BiVO}_4\text{-}0.55\text{TiO}_2$  composition sintered at  $900^\circ\text{C}$  with a  $\epsilon_r \sim 86$ , a  $Qf \sim 9,500$  GHz and a TCF  $\sim -8$  ppm/ $^\circ\text{C}$ . Far-infrared reflectivity fitting indicated that stretching of Bi-O and Ti-O bonds in this system dominated dielectric polarization. This series of ceramics are promising not only for low temperature co-fired ceramic (LTCC) technology but also as substrates for physically and electrically small dielectrically loaded micro-strip patch antennas.

Keywords: (Ceramics, Dielectrics)

## I. Introduction

Microwave dielectric (MW) ceramics are widely used as dielectric resonators (DR), filters, substrates for radio frequency (RF) components and waveguides.<sup>1,2</sup> The driving force for development in MW ceramics depends on applications. For low temperature co-fired ceramics (LTCC) technology, the driving forces are compatibility with low cost electrodes (Ag, Cu, etc.) and reduced sintering temperatures. For resonators and filters, ultra-high quality factors ( $Qf > 40,000 \text{ GHz}$ ) are required to ensure selectivity to in a narrow frequency range and for dielectrically loaded antennas in handheld devices, reduction of size and cost of the component is critical.<sup>3,4</sup> LTCC technology has played an important role in fabrication of modern microwave devices and requires materials with permittivity ( $\epsilon_r$ ) values between 10 - 100,  $Qf$  values  $> 5000 \text{ GHz}$ , near-zero temperature coefficients of resonant frequency ( $\text{TCF} < \pm 15 \text{ ppm}/^\circ\text{C}$ ). Many low  $\epsilon_r$  materials for LTCC technology have been developed and several are commercially available through companies such as Ferro and Dupont.<sup>5,6</sup> However, materials with  $\epsilon_r$  above 70 are rare. The classic method to develop LTCC materials is to add low melting point oxides or glasses to high  $Qf$  microwave dielectric ceramics to lower their sintering temperatures.<sup>3,7,8</sup> The best known commercial high  $\epsilon_r$  microwave dielectric ceramics are the  $\text{BaO-RE}_2\text{O}_3\text{-TiO}_2$  (BRET, RE = La, Nd and Sm) system with properties of  $70 < \epsilon_r < 85$ ,  $8,000 < Qf < 12,000 \text{ GHz}$ , and tunable TCF values near zero but these compositions can only be sintered above  $1300^\circ\text{C}$ .<sup>9-12</sup> Moreover, their sintering temperatures cannot be lowered to below  $1100^\circ\text{C}$  using sintering aids without decreasing  $\epsilon_r$  to less than 70 accompanied by a significant deterioration in  $Qf$  values.<sup>12</sup>

$\text{Bi}_2\text{Ti}_4\text{O}_{11}\text{-TiO}_2$  composites<sup>13,14</sup> belong to the  $\text{Bi}_2\text{O}_3\text{-TiO}_2$  binary system, in which

there are five known single phase compounds:  $\text{Bi}_2\text{Ti}_4\text{O}_{11}$ ;  $\text{Bi}_2\text{Ti}_2\text{O}_7$ ;  $\text{Bi}_4\text{Ti}_3\text{O}_{12}$ ;  $\text{Bi}_8\text{Ti}_4\text{O}_{14}$  and  $\text{Bi}_{12}\text{TiO}_{20}$  as shown in Fig. 1 (a).<sup>15,16</sup> Single phase  $\text{Bi}_2\text{Ti}_4\text{O}_{11}$  ceramic was reported to possess a  $\epsilon_r = 53.2$ , a  $Qf \sim 4,500$  GHz (at 5 GHz), and a TCF =  $-550$  ppm/ $^{\circ}\text{C}$ . Temperature stable microwave dielectric ceramic with composition  $0.919\text{TiO}_2\text{-}0.081\text{Bi}_2\text{O}_3$ , which is composed of  $\text{TiO}_2$  and  $\text{Bi}_2\text{Ti}_4\text{O}_{11}$ , was found to possess a high  $\epsilon_r \sim 80$ , a high  $Q$  (1800 at 5 GHz) and a TCF  $\sim +21$  ppm/ $^{\circ}\text{C}$ .<sup>14</sup> In our previous work,<sup>17</sup> CuO was used as sintering aid in  $0.92\text{TiO}_2\text{-}0.08\text{Bi}_2\text{Ti}_4\text{O}_{11}$  and it lowered the sintering temperature to  $900^{\circ}\text{C}$  whilst maintaining a  $\epsilon_r = 81$ ,  $Qf$  value  $\sim 3,500$  GHz and a TCF  $\sim -5.1$  ppm/ $^{\circ}\text{C}$ . Formation of semiconducting  $\text{Cu}_9\text{Bi}_2\text{Ti}_{12}\text{O}_{36}$  was thought to be responsible for the reduction in  $Qf$  value. Valant et al.<sup>18</sup> also found that nano- $\text{TiO}_2$  additions can further improve  $Qf$ . Besides  $\text{Bi}_2\text{Ti}_4\text{O}_{11}$ , sillenite-structured  $\text{Bi}_{12}\text{TiO}_{20}$  ceramic was reported to possess a  $\epsilon_r \sim 41$ ,  $Qf$  between  $3,300 \sim 10,400$  GHz, and TCF between  $-2 \sim -10.8$  ppm/ $^{\circ}\text{C}$ , according to Valant and Jeong et al.'s reports<sup>19-21</sup>

In Bi-rich part of the  $\text{Bi}_2\text{O}_3\text{-V}_2\text{O}_5$  binary system, there are at least seven known phases,  $\text{Bi}_7\text{VO}_{13}$ ,  $\text{Bi}_5\text{VO}_{10}$ ,  $\text{Bi}_{14}\text{V}_4\text{O}_{31}$ ,  $\text{Bi}_7\text{V}_3\text{O}_{18}$ ,  $\text{Bi}_6\text{V}_4\text{O}_{19}$ ,  $\text{BiVO}_4$ , and  $\text{Bi}_2\text{V}_8\text{O}_{23}$ , according to Touboul and Vachon's report.<sup>22</sup> Lv et al. studied this system via solid state reaction method<sup>23</sup> and based on their XRD analysis, five binary compounds:  $\text{Bi}_{8.1}\text{V}_{0.9}\text{O}_{14}$ ,  $\text{Bi}_7\text{VO}_{13}$ ,  $\text{Bi}_8\text{V}_2\text{O}_{17}$ ,  $\text{Bi}_4\text{V}_2\text{O}_{11}$  and  $\text{BiVO}_4$  were obtained along with two solid solutions:  $x\text{Bi}_2\text{O}_3\text{:V}_2\text{O}_5$  ( $5 \leq x \leq 6$ ) and  $(\text{Bi}_2\text{O}_3)_{1-x}(\text{V}_2\text{O}_5)_x$  ( $0 \leq x \leq 0.069$ ). In the V-rich part, only a meta-stable  $\text{Bi}_2\text{V}_8\text{O}_{23}$  was reported as shown in Fig. 1 (a). Among all the phases in the  $\text{Bi}_2\text{O}_3\text{-V}_2\text{O}_5$  binary system, only  $\text{BiVO}_4$  was reported to possess good microwave properties with a  $\epsilon_r \sim 68$ , a  $Qf$  value between  $6,500 \sim 8,000$  GHz, and a TCF between  $-243 \sim -260$  ppm/ $^{\circ}\text{C}$ .<sup>24,25</sup> Although reported to react with Ag,<sup>24</sup>  $\text{BiVO}_4$ -based ceramics were found to be chemically compatible with Al and Cu

electrodes in our previous work<sup>26</sup> which might extend its application in LTCC technology.

According to Lv's report,<sup>23</sup> three single phase compounds,  $\text{Bi}_{17}\text{V}_2\text{TiO}_{32.5}$ ,  $\text{Bi}_4\text{V}_{1.5}\text{Ti}_{0.5}\text{O}_{10.85}$  and  $\text{Bi}_{13}\text{V}_5\text{TiO}_{34}$  exist in the  $\text{Bi}_2\text{O}_3$ – $\text{TiO}_2$ – $\text{V}_2\text{O}_5$  ternary system and no single phase compounds were reported in the  $\text{V}_2\text{O}_5$ – $\text{TiO}_2$  and  $\text{TiO}_2$ – $\text{BiVO}_4$  binary systems. This indicates that  $\text{TiO}_2$  and  $\text{BiVO}_4$  phases do not react with each other and can co-exist. The absence of single phase compounds in the  $\text{TiO}_2$ – $\text{BiVO}_4$  binary system suggests that immiscible composites may be fabricated.  $\text{TiO}_2$  was reported to have a  $\epsilon_r = 100$  and a  $Qf \sim 14,000$  GHz but a  $\text{TCF} > +400$  ppm/°C.<sup>27</sup>  $\text{BiVO}_4$  was also reported to possess excellent MW properties (a  $\epsilon_r \sim 68$ , a  $Qf$  value between 6,500 ~ 8,000 GHz, and a  $\text{TCF}$  between  $-243 \sim -260$  ppm/°C) and a low sintering temperature about 820 °C. Hence, it attracts us to design novel high permittivity and low sintering temperature composite microwave dielectric ceramics based on the  $\text{TiO}_2$ – $\text{BiVO}_4$  binary system.

In the present work, a series of composite ceramic samples in the  $\text{TiO}_2$ – $\text{BiVO}_4$  binary system were designed and prepared via traditional solid state reaction method. Phase composition, microstructure, microwave dielectric properties and infrared reflectivity were investigated. A wide ternary region in the  $\text{Bi}_2\text{O}_3$ – $\text{TiO}_2$ – $\text{V}_2\text{O}_5$  phase diagram was discovered with high  $\epsilon_r$  and easily adjustable  $\text{TCF}$  values.

## II. Experimental

Proportionate amounts of reagent-grade starting materials of  $\text{Bi}_2\text{O}_3$  (> 99 %, Shu-Du Powders Co. Ltd., Chengdu, China),  $\text{TiO}_2$  and  $\text{V}_2\text{O}_5$  (> 99 %, Sinopharm Chemical Reagent Co., Ltd, Shanghai, China) were measured according to the stoichiometric formulations  $(1-x)\text{BiVO}_4$ – $x\text{TiO}_2$  ( $x=0.4, 0.50, 0.55$  and  $0.60$ ). Powders were mixed

and milled for 4 h using a planetary mill (Nanjing Machine Factory, Nanjing, China) by setting the running speed at 150 rpm with the zirconia balls (2 mm in diameter) as milling media. The powder mixture was then dried and calcined at 800 °C for 4 h. The calcined powders were ball milled for 5 h with a running speed of 200 rpm to obtain fine powders. Then the powders were pressed into cylinders in a steel die with 5 wt. % PVA binder addition under a uniaxial pressure of 150 MPa. Samples were sintered in the temperature range from 850 °C to 920 °C for 2 h. Room temperature X-ray diffraction (XRD) was performed using a XRD with Cu K $\alpha$  radiation (Rigaku D/MAX-2400 X-ray diffractometry, Tokyo, Japan). Prior to examination sintered pellets were crushed in a mortar and pestle to powder. Diffraction pattern was obtained between 2 $\theta$  of 10-65° at a step size of 0.02 °. To examine the grain morphology, as-fired and fractured surfaces were investigated by scanning electron microscopy (SEM, FEI, Quanta 250 F). The room temperature infrared reflectivity spectra were measured using a Bruker IFS 66v FTIR spectrometer on Infrared beamline station (U4) at National Synchrotron Radiation Lab. (NSRL), China. Dielectric properties at microwave frequency were measured with the TE<sub>018</sub> dielectric resonator method with a network analyzer (HP 8720 Network Analyzer, Hewlett-Packard) and a temperature chamber (Delta 9023, Delta Design, Poway, CA). The temperature coefficient of resonant frequency TCF ( $\tau_f$ ) was calculated with the following formula:

$$TCF(\tau_f) = \frac{f_T - f_{T_0}}{f_{T_0} \times (T - T_0)} \times 10^6 \quad (1)$$

where the  $f_T$  and  $f_{T_0}$  were the TE<sub>018</sub> resonant frequencies at temperature T and T<sub>0</sub>, respectively.

### III. Results and Discussions

X-ray diffraction patterns of the  $(1-x)\text{BiVO}_4\text{-}x\text{TiO}_2$  ( $x=0.4, 0.50, 0.55$  and  $0.60$ ) ceramic samples sintered at their optimal temperatures are presented in Fig. 2. Two sets of peaks corresponding to both rutile  $\text{TiO}_2$  and monoclinic scheelite  $\text{BiVO}_4$  phases were revealed, indicating that  $\text{BiVO}_4$  and  $\text{TiO}_2$  coexist at their sintering temperatures, which is consistent with reported data.<sup>23</sup>

In the monoclinic  $\text{BiVO}_4$  structure,  $\text{V}^{5+}$  ions ( $0.355 \text{ \AA}$ ) occupy tetrahedral ( $\text{CN}4$ ) sites and may be substituted for by  $\text{Mo}^{6+}$  ( $0.41 \text{ \AA}$ ),  $\text{W}^{6+}$  ( $0.41 \text{ \AA}$ ),  $\text{Fe}^{3+}$  ( $0.49 \text{ \AA}$ ) and  $\text{In}^{3+}$  ( $0.62 \text{ \AA}$ ).<sup>28</sup>  $\text{Ti}^{4+}$  has similar ionic radius ( $0.42 \text{ \AA}$  in  $\text{CN}4$ ) to that of  $\text{V}^{5+}$  but prefers to remain in octahedral coordination within the rutile structure (note  $\text{Ti}^{4+}$  has a strong octahedral site preference in most structures, such as  $\text{ABO}_3$  perovskite<sup>29</sup>), permitting chemical and structural immiscibility between  $\text{BiVO}_4$  and  $\text{TiO}_2$ .

Back-scattering electron images (BEI) of the as-fired and fractured surfaces of  $0.45\text{BiVO}_4\text{-}0.55\text{TiO}_2$  ceramics sintered at  $890^\circ\text{C}$  for 2 hr and EDS results are shown in Fig. 3. Dense microstructure are revealed and there are two different kinds of grains with white and black contrast. According to EDS analysis, the regions of white and dark contrast are  $\text{BiVO}_4$  and  $\text{TiO}_2$ , respectively. The grain size of  $\text{BiVO}_4$  is  $\sim 5 \mu\text{m}$ , which is similar to the reported value,<sup>26</sup> even though the sintering temperature is higher than that of pure  $\text{BiVO}_4$  ceramic ( $840^\circ\text{C}$ ). Usually rutile  $\text{TiO}_2$  can be densified at high sintering temperature above  $1300^\circ\text{C}$  and here the grain size remains  $< 1 \mu\text{m}$ . Fractured surfaces corresponded well with as-fired ones and BEI further confirmed the coexistence of  $\text{BiVO}_4$  and  $\text{TiO}_2$  phases.

$\epsilon_r$ ,  $Qf$ , and TCF as a function of composition and temperature in  $(1-x)\text{BiVO}_4\text{-}x\text{TiO}_2$  are shown in Fig. 4.  $\epsilon_r$  of  $\text{BiVO}_4$  and  $\text{TiO}_2$  are 68 and 104, respectively, at microwave



frequencies. Here  $\epsilon_r$  increased linearly from 68.5 at  $x=0.0$  to 87.7 at  $x=0.6$ . This was accompanied by a commensurate increase in TCF values from  $-260 \text{ ppm/}^\circ\text{C}$  for pure  $\text{BiVO}_4$  to  $+46 \text{ ppm/}^\circ\text{C}$  at  $x=0.6$ . A near-zero TCF ( $-8 \text{ ppm/}^\circ\text{C}$ ) was achieved in compositions with  $x=0.55$ . Sintering temperature increased from  $840^\circ\text{C}$  for pure  $\text{BiVO}_4$  to  $890^\circ\text{C}$  at  $x=0.4$ , after which it remained stable up to  $x=0.6$ . In contrast to the linear trends described above for  $\epsilon_r$  and TCF values,  $Qf$  values exhibited non-linear behavior as a function of  $x$ . First  $Qf$  increased to  $\sim 12,290 \text{ GHz}$  at  $x=0.4$  but decreased to  $9,500 \text{ GHz}$  at  $x=0.55$ . As reported by Alford,<sup>30</sup> the dielectric loss of  $\text{TiO}_2$  ceramics doped with divalent and trivalent ions with ionic radii in the range of  $0.5 \sim 0.95 \text{ \AA}$  can be very low ( $Q \sim 17,000$ ) at room temperature, which might be attributed to the prevention of formation of  $\text{Ti}^{3+}$ . In the present work, small amount of  $\text{V}^{5+}$  might hold the Ti site in rutile structure. A series of modifications based on  $0.45\text{BiVO}_4\text{-}0.55\text{TiO}_2$  composite were designed on the premise that the large difference in sintering temperatures between  $\text{BiVO}_4$  and  $\text{TiO}_2$  ceramics may cause defects at grain boundaries.<sup>30,31</sup> Therefore, a series of modified rutile structured  $\text{Ti}_{1-x}(\text{Cu}_{1/4}\text{Nb}_{3/4})_x\text{O}_2$  ( $\epsilon_r \sim 95$ ,  $Qf \sim 35,000 \text{ GHz}$ ,  $\text{TCF} \sim +400 \text{ ppm/}^\circ\text{C}$ )<sup>32</sup> and  $\text{Ti}_{1-x}(\text{Cu}_{1/3}\text{Ta}_{2/3})_x\text{O}_2$  materials with low sintering temperatures were chosen to replace pure  $\text{TiO}_2$  in the  $0.45\text{BiVO}_4\text{-}0.55\text{TiO}_2$  composite. Moreover, we have previously shown that  $Qf$  of  $\text{BiVO}_4$  was improved by substitution on both A and B sites. Hence,  $\text{Bi}(\text{Fe},\text{Mo},\text{V})\text{O}_4$ ,  $(\text{Na},\text{Bi})(\text{Mo},\text{V})\text{O}_4$  series<sup>33,34</sup> were chosen to replace pure  $\text{BiVO}_4$  in  $0.45\text{BiVO}_4\text{-}0.55\text{TiO}_2$  composite. In addition, nano-sized  $\text{TiO}_2$  (20 nm) particles were also utilized to form composites. The results of these studies are listed in Table I. Despite modification to sintering temperature, properties of the composite end members did not increase as expected and  $Qf$  remained between  $9,000 \sim 12,330 \text{ GHz}$ . Furthermore, to avoid any possibility of interfacial defects between  $\text{BiVO}_4$  and  $\text{TiO}_2$

caused during the sintering process, macroscopic composites of well sintered and polished  $\text{BiVO}_4$  and  $\text{TiO}_2$  ceramics samples bonded with adhesive were also measured. Similar  $Qf$  values were obtained suggesting that the unexpected decrease of  $Qf$  might not arise from defects during sintering but were intrinsic. It is important to note that for a given sample dimension, the resonant frequency of composites with larger  $\epsilon_r$  will be less than those with lower  $\epsilon_r$ . Consequently,  $Qf$  values for  $\text{BiVO}_4$ ,  $\text{TiO}_2$  and  $0.45\text{BiVO}_4\text{-}0.55\text{TiO}_2$  composite samples were measured at different resonant frequencies. To a first approximation,  $Qf$  is considered as a material constant, however, it is well known that<sup>35</sup> for different materials  $Qf$  values usually change slightly as a function of frequency and this might be the reason of the unexpected decrease in  $Qf$  values. Anyway, there is no strong evidence here supporting the intrinsic or extrinsic decrease in  $\text{BiVO}_4\text{-TiO}_2$  composites when  $x > 0.4$  and this needs further study in detail.

The temperature dependence of  $\epsilon_r$  and  $Qf$  of the  $(1-x)\text{BiVO}_4\text{-}x\text{TiO}_2$  ( $x=0.4, 0.5$  and  $0.55$ ) are presented in Fig. 4 (c). Temperature stable  $\epsilon_r=86$  and  $Qf=9,500$  GHz were obtained over a wide temperature range  $20 \sim 125$  °C, which is illustrating that compensation of TCF was achieved using composites of  $\text{BiVO}_4$  and  $\text{TiO}_2$ . According to Ref,<sup>26</sup>  $\text{BiVO}_4$  does not react with copper and aluminum at low sintering temperatures and  $\text{TiO}_2$  was also reported to be chemically compatible with silver.<sup>18</sup> It is therefore possible that a compatible base metal electrode system could be developed for co-firing with  $(1-x)\text{BiVO}_4\text{-}x\text{TiO}_2$  composites. The sintering temperatures and microwave dielectric properties of some high  $\epsilon_r$  microwave dielectric ceramics are listed in Table II for comparison<sup>34-36</sup> with the composites fabricated in this study. The  $(1-x)\text{BiVO}_4\text{-}x\text{TiO}_2$  composites possess both low sintering temperatures and good microwave dielectric properties. Therefore, based on the data

shown in Fig. 1 (b), a series of temperature stable microwave dielectric ceramics might be achievable in the  $\text{Bi}_2\text{O}_3\text{-TiO}_2\text{-V}_2\text{O}_5$  ternary system along the composition line  $(0.88\text{TiO}_2\text{-}0.12\text{Bi}_2\text{Ti}_4\text{O}_{11})\text{-(}0.45\text{BiVO}_4\text{-}0.55\text{TiO}_2\text{)}$ . Besides LTCC technology with suitable electrode, such materials also have great potential for dielectric substrates in ultra-small dielectrically-loaded micro-strip patch antennas. The current generation of substrates utilize compositions based on BRET,<sup>36-38</sup> which have sintering temperatures above 1300 °C. Moreover, BRET compositions with comparable  $\epsilon_r$  (86.2) have lower  $Qf$  than that of the composites described in this contribution.  $\text{BiVO}_4\text{-TiO}_2$  composites therefore offer a low sintering temperature, RE-free, and high  $Qf$  alternative to BRET.

To further study the intrinsic microwave dielectric properties, infrared reflectivity spectra of the  $0.45\text{BiVO}_4\text{-}0.55\text{TiO}_2$  ceramic were analyzed using a classical harmonic oscillator model:

$$\epsilon^*(\omega) = \epsilon_\infty + \sum_{j=1}^n \frac{\omega_{pj}^2}{\omega_{oj}^2 - \omega^2 - j\gamma_j\omega}, \quad (2)$$

where  $\epsilon^*(\omega)$  is complex dielectric function,  $\epsilon_\infty$  is the dielectric constant caused by the electronic polarization at high frequencies,  $\gamma_j$ ,  $\omega_{oj}$ , and  $\omega_{pj}$  are the damping factor, the transverse frequency, and plasma frequency of the  $j$ -th Lorentz oscillator, respectively, and  $n$  is the number of transverse phonon modes.  $\epsilon_\infty$  is the dielectric constant caused by the electronic dispersive polarization at optical frequency. Assuming that within the microwave region  $\omega \ll \omega_{oj}$ , the real part and imaginary part of microwave permittivity can be written as:

$$\epsilon'(\omega) = \epsilon_\infty + \sum_{j=1}^n \Delta\epsilon'_j = \epsilon_\infty + \sum_{j=1}^n \frac{\omega_{pj}^2}{\omega_{oj}^2}, \quad (3)$$

$$\epsilon''(\omega) = \sum_{j=1}^n \frac{\gamma_j \omega_{pj}^2}{\omega_{oj}^2} \omega, \quad (4)$$

and the complex reflectivity  $R(\omega)$  can be written as:

$$R(\omega) = \left| \frac{1 - \sqrt{\epsilon^*(\omega)}}{1 + \sqrt{\epsilon^*(\omega)}} \right|^2. \quad (5)$$

Fitted infrared reflectivity values, complex permittivities and phonon parameters are shown in Fig. 5 and Table III. The calculated  $\epsilon_r$  and dielectric loss values match well those measured using TE<sub>01δ</sub> method, which implies that the majority of the dielectric contribution to this system at microwave frequencies may be attributed to the absorptions of structural phonon oscillations in the infrared region and very little contribution was from defect phonon scattering. The optical dielectric constant calculated from the infrared spectra is about 5.87, which is only 7 % percent of the total polarizability contribution at microwave frequencies, and this implies that the main polarization contributions to microwave permittivity of high  $\epsilon_r$  materials come from ionic polarization rather than electronic. Contributions from each mode is listed as  $\Delta\epsilon_j$  in Table III. The contributions from the first four modes, which are below 200 cm<sup>-1</sup>, can reach 70.15 and about 85% of the total value, which means that the stretching of Bi-O and Ti-O bond lengths determine the main dielectric polarization rather than bending modes. This conclusion corresponds well with our previous studies.<sup>2, 33</sup>

## IV. Conclusions

In the present work, temperature stable high  $\epsilon_r$  microwave dielectric ceramics were explored in the Bi<sub>2</sub>O<sub>3</sub>-TiO<sub>2</sub>-V<sub>2</sub>O<sub>5</sub> ternary system. The 0.45BiVO<sub>4</sub>-0.55TiO<sub>2</sub> ceramics sintered at 900 °C for 2 h possessed excellent microwave dielectric properties with a  $\epsilon_r \sim 86$ , a  $Qf \sim 9,500$  GHz and a near-zero TCF  $\sim -8$  ppm/°C. These composite ceramics were composed of both scheelite-structured BiVO<sub>4</sub> (with large negative TCF)

and rutile  $\text{TiO}_2$  (with large positive TCF), which was supported both by the XRD and EDS analysis. Far-infrared reflectivity fitting indicated that stretching of the Bi-O and Ti-O bonds in this system dominate the dielectric polarization. Therefore, along with the  $\text{TiO}_2\text{-Bi}_2\text{Ti}_4\text{O}_{11}$  system, the  $\text{Bi}_2\text{O}_3\text{-TiO}_2\text{-V}_2\text{O}_5$  ternary system presents a wide compositional region with easily adjustable  $\epsilon_r$  and TCF that can be fabricated by a traditional solid state reaction method at  $900^\circ\text{C}$ . The materials therefore have great potential for exploitation both in LTCC technology and ultra-small, dielectrically-loaded micro-strip patch antennas applications with RE-free composition, lower sintering temperature, and higher  $Q_f$  alternative to BRET materials.

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## Table Captions:

Table I. Microwave dielectric properties of some modifications of 0.45BiVO<sub>4</sub>-0.55TiO<sub>2</sub> ceramics

Table II. Sintering temperatures (S.T.) and microwave dielectric properties of high-K microwave dielectric ceramics

Table III. Phonon parameters obtained from the fitting of the infrared reflectivity spectra of 0.45BiVO<sub>4</sub>-0.55TiO<sub>2</sub> ceramic

Table I. Microwave dielectric properties of some modifications of 0.45BiVO<sub>4</sub>-0.55TiO<sub>2</sub> ceramics

Compositions	S.T. (°C)	ε <sub>r</sub>	Qf (GHz)	TCF (ppm/°C)
0.45Bi(Fe,Mo,V)O <sub>4</sub> -0.55TiO <sub>2</sub>	880	74.8	9,300	+22
Bi(Fe,Mo,V)O <sub>4</sub> -TiO <sub>2</sub>	stack	75.4	9,240	+18
0.45(Na,Bi)(Mo,V)O <sub>4</sub> -0.55TiO <sub>2</sub>	870	83.8	8,300	+15
0.45BiVO <sub>4</sub> -0.55	870	79.8	12,330	-65
Ti <sub>1-x</sub> (Cu <sub>1/4</sub> Nb <sub>3/4</sub> ) <sub>x</sub> O <sub>2</sub> (x=0.15)				
0.45BiVO <sub>4</sub> -0.55	890	78.7	10,240	-46
Ti <sub>1-x</sub> (Cu <sub>1/4</sub> Ta <sub>3/4</sub> ) <sub>x</sub> O <sub>2</sub> (x=0.15)				
0.45BiVO <sub>4</sub> -0.55TiO <sub>2</sub> (nano~20μm)	870	80.5	9,500	+10
0.45BiVO <sub>4</sub> -0.55TiO <sub>2</sub>	900	86.2	9,500	-8

Table II. Sintering temperatures (S.T.) and microwave dielectric properties of high-K microwave dielectric ceramics

Compositions	S.T. (°C)	$\epsilon_r$	Qf (GHz)	TCF (ppm/°C)	Ref.
BiVO <sub>4</sub>	820	68	8,500	-260	24,25
0.88TiO <sub>2</sub> -0.12Bi <sub>2</sub> Ti <sub>4</sub> O <sub>11</sub>	>1150	81	6,500~8,500	+8~15	13,14,17
TiO <sub>2</sub> (nano)-Bi <sub>2</sub> Ti <sub>4</sub> O <sub>11</sub> -CuO	915	80	9,500	0	19
Ba <sub>6-x</sub> Sm <sub>8+2x</sub> Ti <sub>18</sub> O <sub>54</sub> (x=2/3)	1400	80	10,700	-15	31
Ba <sub>6-x</sub> (Sm,Nd) <sub>8+2x</sub> Ti <sub>18</sub> O <sub>54</sub>	1350	78.9	9,060	-5.3	36
TiO <sub>2</sub> -Bi <sub>2</sub> Ti <sub>4</sub> O <sub>11</sub> -CuO	900	81.5	3,500	-5.1	18
Bi(Fe,Mo,V)O <sub>4</sub>	820	74.8	13,000	+20	30
(Li,Bi)(MoV)O <sub>4</sub>	650	81	8,000	-90~+9.7	26
0.5BiVO <sub>4</sub> -0.5TiO <sub>2</sub>	900	85.6	11,650	-55	This work
<b>0.45BiVO<sub>4</sub>-0.55TiO<sub>2</sub></b>	<b>900</b>	<b>86.2</b>	<b>9,500</b>	<b>-8</b>	<b>This work</b>
0.45BiVO <sub>4</sub> -0.55TiO <sub>2</sub> (nano)	870	80.5	9,500	+10	This work
0.4BiVO <sub>4</sub> -0.6TiO <sub>2</sub>	900	87.7	8,240	+46	This work
TiO <sub>2</sub>	1300	100	20,000	+400	13
CaO-Li <sub>2</sub> O-Ln <sub>2</sub> O <sub>3</sub> -TiO <sub>2</sub>	1400	110	4,500	+7	38

Table III. Phonon parameters obtained from the fitting of the infrared reflectivity spectra of 0.45BiVO<sub>4</sub>-0.55TiO<sub>2</sub>ceramic

Mode	$\omega_{oj}$	$\omega_{pj}$	$\gamma_j$	$\Delta\epsilon_j$
1	82.52	412.86	23.27	25.0
2	109.60	607.09	44.64	30.7
3	145.62	483.00	43.22	11.0
4	177.53	329.58	42.45	3.45
5	255.28	263.79	53.14	1.07
6	273.07	126.68	17.50	0.22
7	310.41	289.19	43.68	0.87
8	346.43	224.05	35.31	0.42
9	400.66	344.27	57.39	0.74
10	535.28	559.14	102.07	1.09
11	632.53	821.63	106.98	1.69
12	675.01	610.32	108.10	0.82
0.45BiVO <sub>4</sub> -0.55TiO <sub>2</sub>	$\epsilon_{\infty}$ =5.87		$\epsilon_0$ =82.2	

## Figure Captions:

**Fig. 1.** Schematic of phase diagram of the  $\text{Bi}_2\text{O}_3\text{-TiO}_2\text{-V}_2\text{O}_5$  binary system after Touboul and Lv's reports (a)<sup>22,23</sup> and a promising region for temperature stable microwave dielectrics (b)

**Fig. 2.** X-ray diffraction patterns of the  $(1-x)\text{BiVO}_4\text{-}x\text{TiO}_2$  ( $x=0.4, 0.50, 0.55$  and  $0.60$ ) ceramic samples sintered at their optimal temperatures (o—rutile phase; \*—scheelite).

**Fig. 3.** Back-scattered electron images of the as-fired (a) and fractured (b) surfaces of the  $0.45\text{BiVO}_4\text{-}0.55\text{TiO}_2$  ceramics sintered 2h at  $890^\circ\text{C}$  (The associated energy dispersive X-ray spectrum is inserted)

**Fig. 4.** Microwave  $\epsilon_r$  and  $Qf$  (a), sintering temperature and TCF (b) as a function of  $x$  in the  $(1-x)\text{BiVO}_4\text{-}x\text{TiO}_2$  compositions and their temperature dependence (c).

**Fig. 5.** Measured and calculated infrared reflectivity spectra (solid line for fitting values and circle for measured values) and fitted complex dielectric spectra of  $0.45\text{BiVO}_4\text{-}0.55\text{TiO}_2$  ceramic (circles are experimental in microwave region).

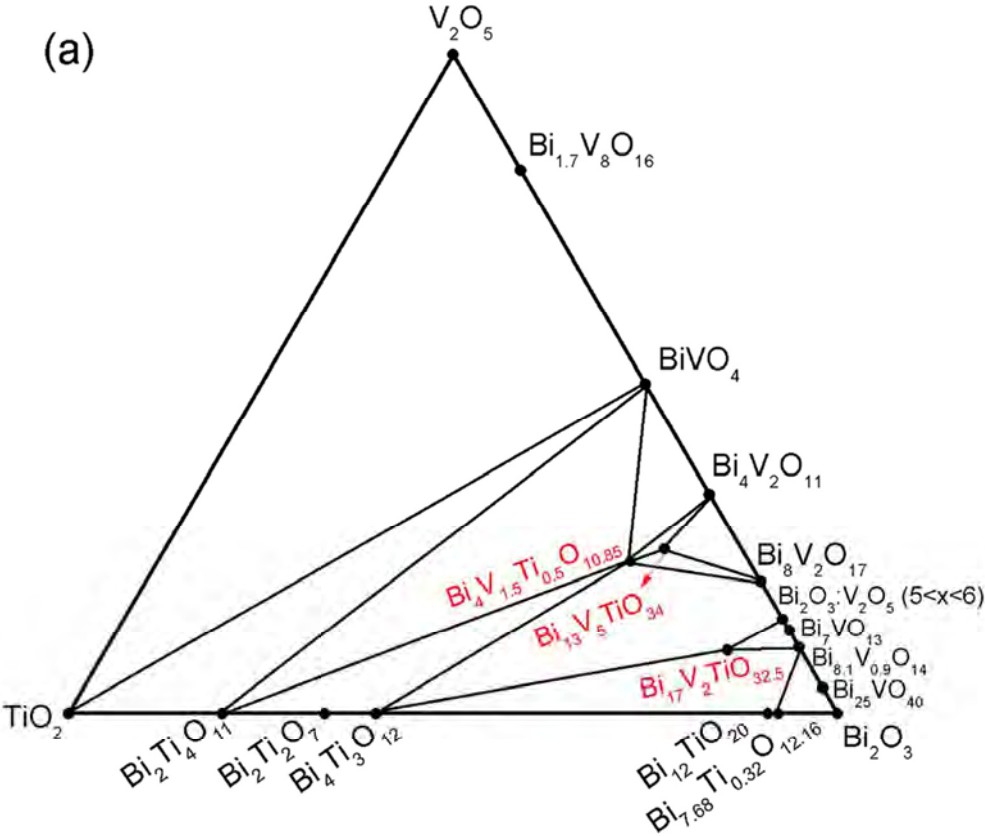


Fig. 1. Schematic of phase diagram of Bi2O3-TiO2-V2O5 binary system after Touboul and Lv'(a) [22, 23] and a promising region for temperature stable microwave dielectrics (b)  
84x72mm (300 x 300 DPI)

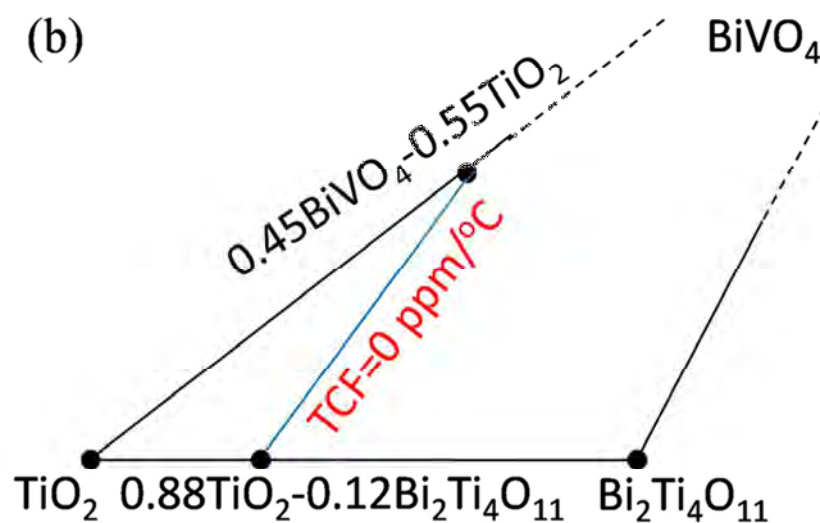


Fig. 1. Schematic of phase diagram of Bi<sub>2</sub>O<sub>3</sub>-TiO<sub>2</sub>-V<sub>2</sub>O<sub>5</sub> binary system after Touboul and Lv'(a) [22, 23] and a promising region for temperature stable microwave dielectrics (b)  
84x50mm (300 x 300 DPI)

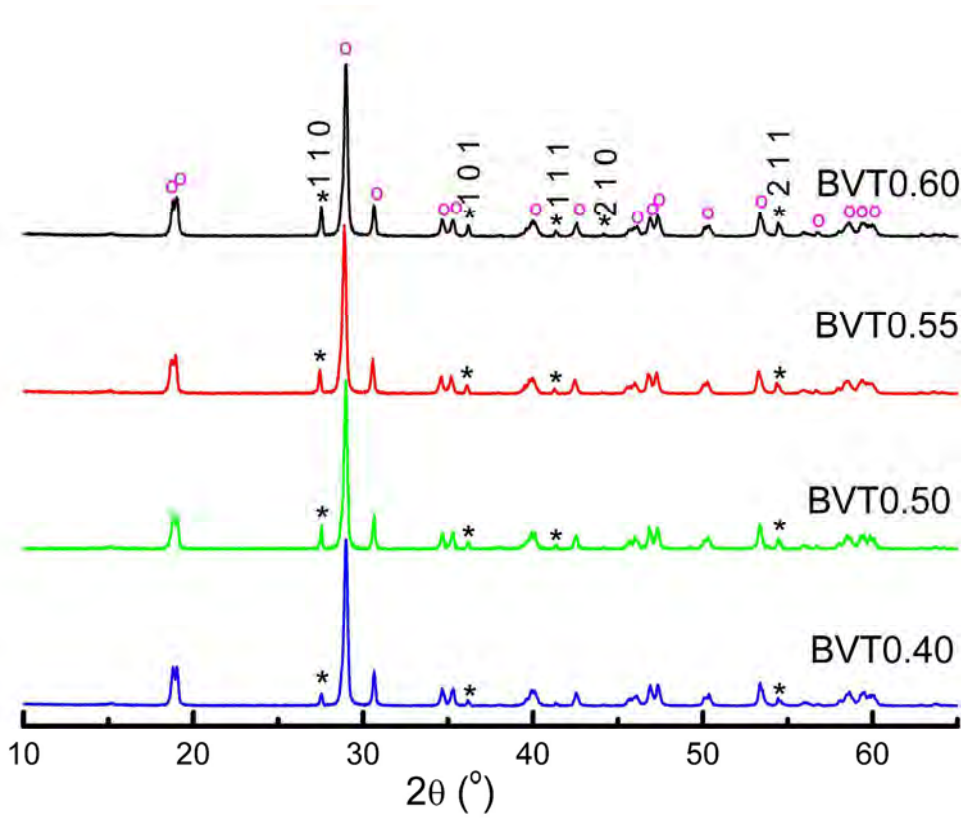


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87x72mm (600 x 600 DPI)



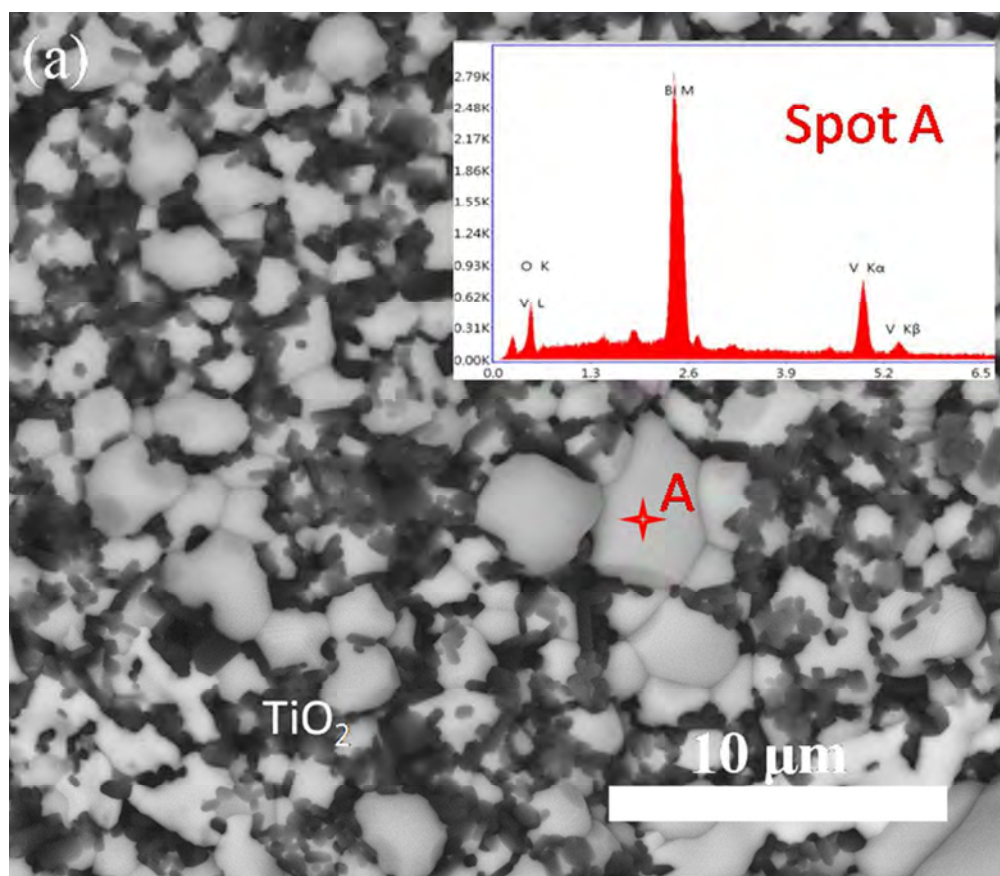


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84x73mm (300 x 300 DPI)

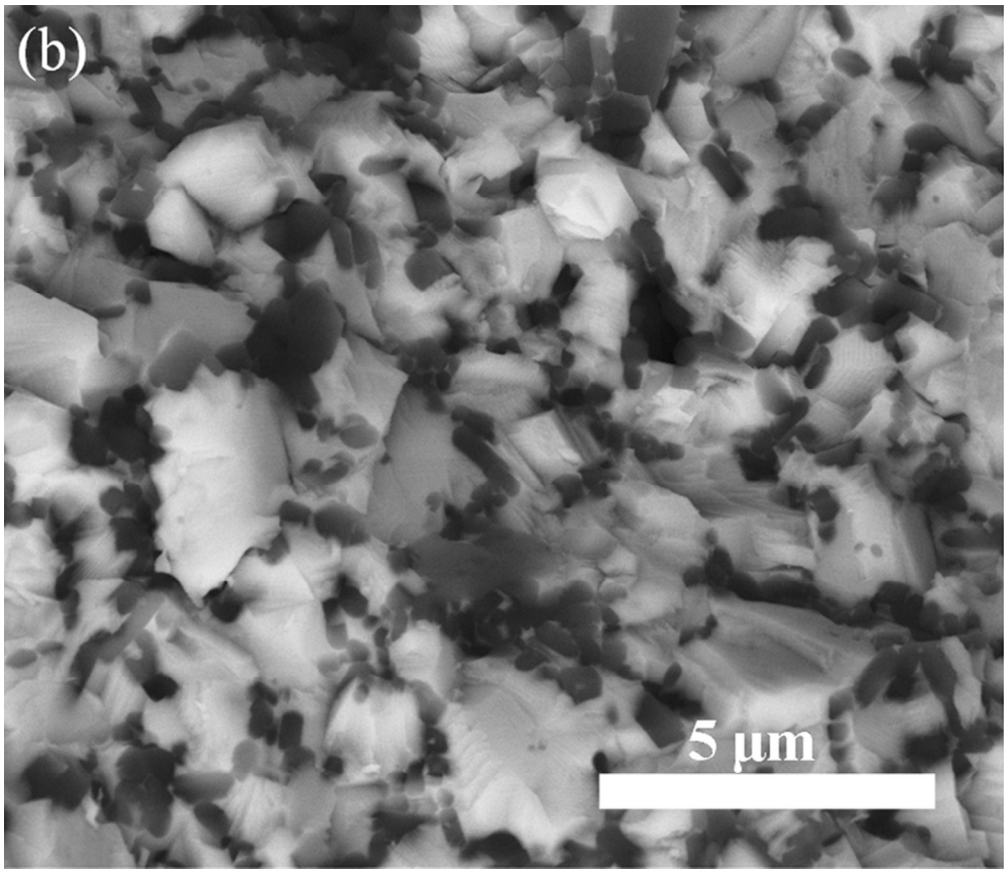


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84x72mm (300 x 300 DPI)

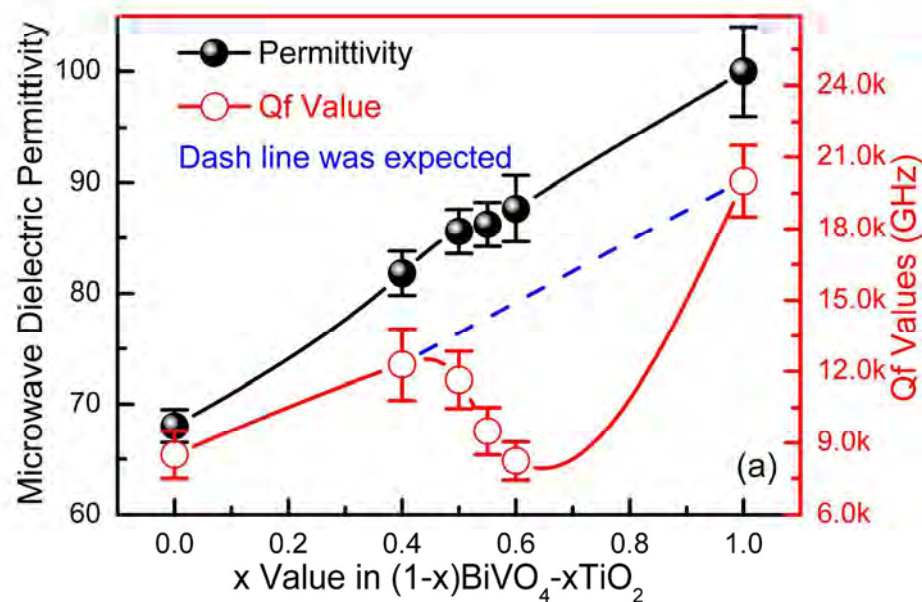


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95x66mm (600 x 600 DPI)

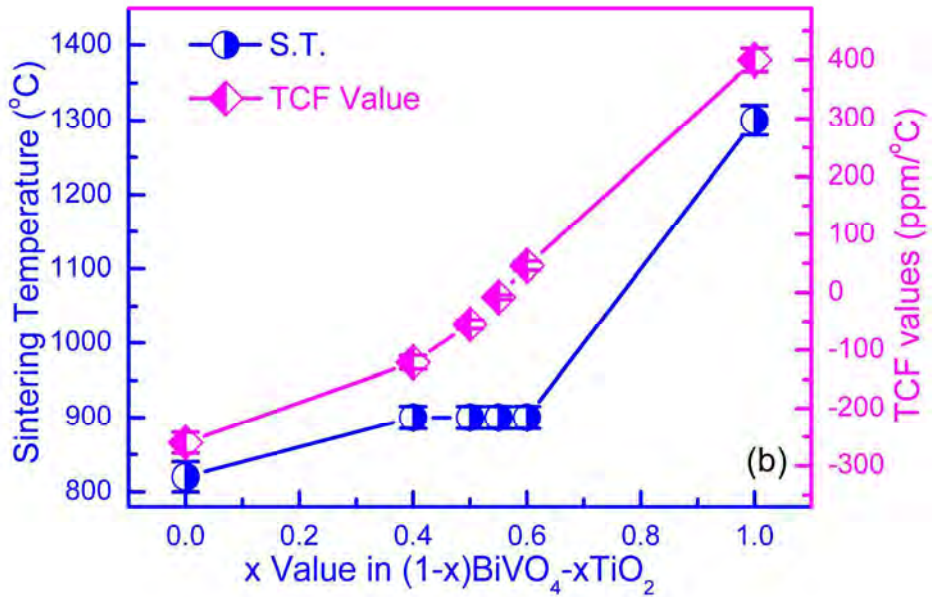


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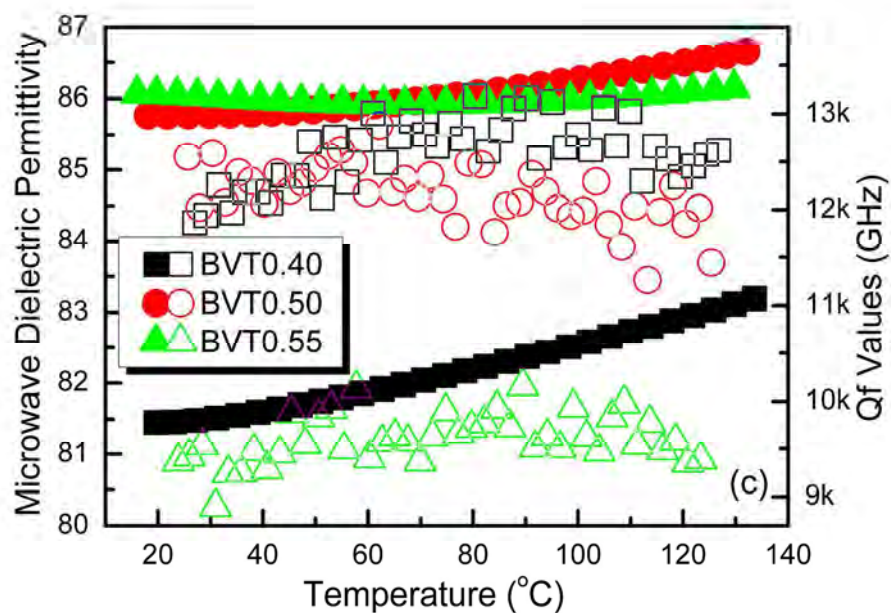


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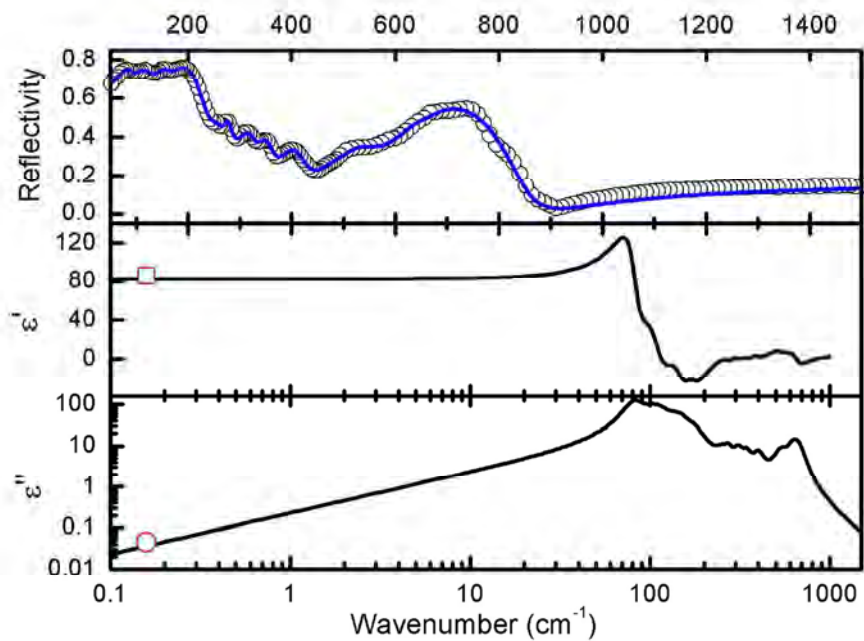
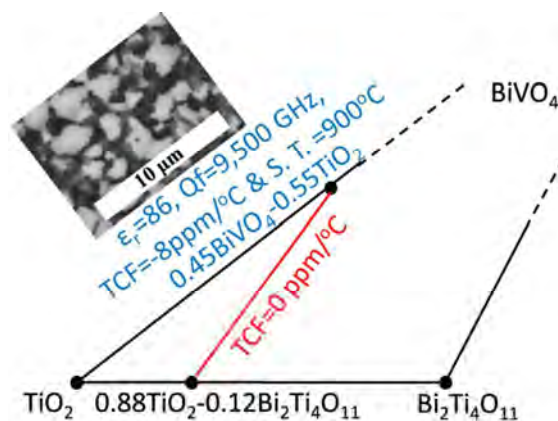


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63x44mm (600 x 600 DPI)





Temperature stable microwave dielectric ceramics were obtained for compositions with  $0.45\text{BiVO}_4\text{-}0.55\text{TiO}_2$  sintered at  $900^\circ\text{C}$  with  $\epsilon_r \sim 86$ , a  $Qf \sim 9,500$  GHz and  $\text{TCF} \sim -8$  ppm/ $^\circ\text{C}$ . It is promising for both low temperature co-fired ceramic technology and dielectrically loaded micro-strip patch antennas substrates. Far-infrared reflectivity fitting indicated that stretching of Bi-O dominated dielectric polarization.